

214019US-2

\$\famolt A \quad 9.16.02 \(C. W) vore

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF:

EIJI SAKAGAMI

:EXAMINER: H. WEISS

SERIAL NO.: 09/955,076

FILED: SEPTEMBER 19, 2001

:GROUP ART UNIT: 2814

FOR: NONVOLATILE SEMICONDUCTOR MEMORY

AND METHOD OF FABRICATING THE SAME

AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

In response to the Official Action dated June 6, 2002, please amend the aboveidentified patent application as follows:

IN THE TITLE

Please amend the title as follows:

NONVOLATILE SEMICONDUCTOR MEMORY HAVING MONOS STRUCTURE AND METHOD OF FABRICATING THE SAME USING SHALLOW TRENCH ISOLATION

IN THE CLAIMS

Please amend Claim 1 to read as follows:¹

1. (Amended) A nonvolatile semiconductor memory comprising:

a semiconductor substrate;

¹The changes to Claim 1 are denoted using underscoring and bracketing in the marked-up copy herewith.